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APPLICATION DATA SHEET

APPLICATION INFORMATION

Application Number::

Filing Date:: May 18, 2006

Application type:: Regular

Subject Matter:: Utility

Title:: Plasma Film-Forming Apparatus and

Plasma Film-Forming Method

Attorney Docket No.:: 101994.57726US

Request for Early Publication?:: No

Request for Non-Publication?:: No

Suggested Drawing Figure:: 1

Total Drawing Sheets:: 10

Small Entity?:: No

Petition included?:: No

APPLICANT INFORMATION

Applicant one Authority Type:: Inventor

Primary Citizenship Country:: JAPAN

Status:: Full Capacity

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CORRESPONDENCE INFORMATION

Correspondence customer number::

23911

REPRESENTATIVE INFORMATION

Representative customer number::

23911

DOMESTIC PRIORITY INFORMATION

Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This	National Stage	PCT/JP2004/017162	11/18/2004
application is a	of		

FOREIGN PRIORITY INFORMATION

Country:: JAPAN	Application Number.::	Filing Date:: 11/19/2003	Priority Claimed:: Yes
	2003-389469		

ASSIGNEE INFORMATION

Assignee Name::

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